

D1384-XY-aQ110-7



High Power Dual Axis AO Deflector

0818

The D1384-XY offers high speed dual axis scanning at 515nm. This deflector consists of two AO deflectors mounted orthogonally in one assembly, with independent fine thread Bragg angle adjustment. A half wave plate is included to rotate the input polarization between AO deflectors. Applications include:

- Material Processing
 Drilling
- Surface texturing
- Micro machining

SPECIFICATIONS

Operating Wavelength: Interaction Material: Active Aperture: H=7

Centre Frequency (x=fc): Sweep Bandwidth:

Diffraction Efficiency (DE) at fc: Diffraction Efficiency across scan: RF Power for max' DE Static Insertion Loss:

Bragg Angle 515nm: Separation Angle at fc: Scan Angle: Input Laser Polarization: Water Cooling (Minimum):

Deflector Performance: Total XY Diffraction Efficiency Access Time: Resolution: 515 nm (contact Isomet for other VIS wavelengths) Quartz 7mmH x 7mmW

110MHz (+/- 5% for best scan response) 30MHz minimum

> 85%, 90% typical per axis
 > 80%, 85% typical per axis
 < 30 Watts total per axis
 < 4%

5.0 mrad 9.9 mrad 2.7 mrad (30MHz sweep). Linear, Vertical w.r.t. to X-axis > 2 Liter/Min. @ < 23°C

Using 5 x 5mm beam > 60% across 30MHz scan 0.9µsec 25 x 25 <u>resolvable</u> spots >1000 x 1000 non-resolvable points (driver dependent)



TYPICAL SCAN RESPONSE per AXIS

ALL SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICEISOMET CORP, 10342 Battleview Parkway, Manassas, VA 20109, USA.Tel: (703) 321 8301Fax: (703) 321 8546E-mail: ISOMET@ ISOMET.COMWeb Page: WWW.ISOMET.COM

Quality Assured. In-house: Crystal Growth, Optical Polishing, A/R coating, Vacuum Bonding

